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PATENT ABSTRACTS OF JAPAN

(11)Publication number : 2005-054158

(43)Date of publication of application : 03.03.2005

(51)Int.Cl. C08L 83/06
C08K 5/02
C08K 5/08

(21)Application number : 2003-289456

(71)Applicant : KAWASAKI KASEI CHEM LTD

(22)Date of filing : 07.08.2003

(72)Inventor : NUMATA SHIGEAKI

(54) PHOTO-CURABLE SILICONE COMPOSITION

(57)Abstract:

PROBLEM TO BE SOLVED: To provide a photo-curable silicone composition capable of being easily cured to form a film, by being irradiated with light, such as ultraviolet light, in a short time, and capable of forming the film having excellent releasability, without using a solvent.

SOLUTION: This photo-curable silicone composition contains an epoxy-modified silicone in an amount of 100 pts.wt., an onium salt photopolymerization initiator in an amount of 0.1-1 pt.wt., and a 9,10-diakloxyanthracene as a sensitizing agent in an amount of 0.001-1 pt.wt., wherein alkoxy groups of the 9,10-diakloxyanthracene are each a 6-12C alkoxy having a side chain.